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Metal–semiconductor Phase-transition in WSe$_{2(1-x)}$Te$_{2x}$ Monolayer

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Keywords: Semiconductor, Metal, Two-dimensional materials, Field-effect transistor, Band gap

In order to produce tunable high-performance electronic devices, bandgap engineering by alloying different semiconductors have been demonstrated in the bulk semiconductors,[1,2] such as Al$_x$Ga$_{1-x}$As for quantum structures, CuIn$_x$Ga$_{1-x}$Se$_2$ for solar cells, In$_x$Ga$_{1-x}$N for light emitting diodes, and Hg$_x$Cd$_{1-x}$Te for infrared detectors, respectively. Recently, the band gap engineering has been realized in monolayer ternary dichalcogenides (TMDs) with 2H phase.
For example, alloy MoS$_{2x}$Se$_{2(1-x)}$ monolayer$^{[3-6]}$ with tunable chemical composition have been realized, as well as the W$_x$Mo$_1$-$_x$S$_2$ and W$_x$Mo$_1$-$_x$Se$_2$.$^{[6-9]}$ However, only a few hundred milli-electron volts (meV) can be tuned for these ternary layers, ~ 300 meV for W$_x$Mo$_1$-$_x$S$_2$ and ~500 meV for MoS$_{2x}$Se$_{2(1-x)}$.$^{[3-7]}$ To be precise. Recently, the transition from semiconducting to metallic 2D MoTe$_2$ has been reported by realizing a ultra-low contact resistance at the heterostructured interface of 2H and 1Td MoTe$_2$.$^{[10]}$ These works inspire the synthesis of novel 2D materials with metal-semiconductor transition for applications in nanoelectronics and nanophotonics. Therefore, a unique ternary 2D material with tunable semiconductor-metal transition, preferably controlled by its chemical composition or ternary ratio, are urgently required to fill such gap. It is well known that WSe$_2$ is a p-type 2D semiconductor with an indirect band gap (1.2 eV) for bulk and direct band gap (1.65 eV) for monolayer, respectively.$^{[11-16]}$ It generally shows 2H crystal structure. On the other hand, WTe$_2$ is a semimetal with 1Td crystal structure, displaying an extremely large magnetoresistance effect in its diamagnetic single crystals.$^{[17-21]}$ The marriage of these two materials suggests a possible route for creating a ternary TMD layer to realize a semiconductor-metal phase transition.

In this work, ternary WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–1) have been synthesized via chemical vapor transport (CVT) in a one-step synthesis, which exhibit two distinct structures (2H and 1Td, corresponding to semiconductor and metal, respectively). Three regions (2H phase, the coexistence of 2H and 1Td phase, and 1Td phase) have been identified in the complete composition of the alloy. Energy dispersive X-ray (EDX) and X-ray photoelectron spectroscopy (XPS) characterization confirm the existence of W, Se and Te with a controlled ratio. Atomic resolution scanning transmission electron microscope (STEM) images further reveal the atomic structure of the alloyed monolayers with different Te alloying concentrations and how they evolve from 2H to the distorted 2H phase, and finally reshape into 1Td phase. Raman spectra identify different phases (2H and 1Td phases) and
composition variations in the WSe$_{2(1-x)}$Te$_{2x}$ alloy. The optical band gap of 2H WSe$_{2(1-x)}$Te$_{2x}$ monolayer have been estimated by photoluminescence (PL) spectra. The electrical properties of atomic layered 2H WSe$_2$, 2H WSe$_{1.4}$Te$_{0.6}$, 1Td WSe$_{0.6}$Te$_{1.4}$ and 1Td WTe$_2$ FETs have been systematically studied, which indicate 2H phase is p-type semiconductor and 1Td phase is a metal. Additionally, the p-type WSe$_{2(1-x)}$Te$_{2x}$ FETs exhibit excellent electronic characteristic with effective hole carries mobility up to 46 cm$^2$V$^{-1}$s$^{-1}$ and on/off ratios up to $10^6$.

The single crystals of WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–1.0) alloys have been synthesized by the method of chemical vapor transport (CVT) with a small amount of iodine (I) as the transport agency, shown in Figure S1. It is noted that 2H and 1Td WSe$_{2(1-x)}$Te$_{2x}$ single crystals form into platelets and strips, respectively, which are in agreement with their own crystalline space groups (hexagonal $P6_3/mmc$ and orthorhombic $Pmn2_1$, respectively), as shown in Figure 1a.$^{11,17}$ The crystal structure of 2H WSe$_{2(1-x)}$Te$_{2x}$ is similar to 2H MoS$_2$. It consists of the WSe$_6$ or WSe/Te$_6$ triangular prism layers bonded together by weak van der Waal’s forces, as shown in Figure 1b. While 1Td WSe$_{2(1-x)}$Te$_{2x}$ compose of the WTe$_6$ or WSe/Te$_6$ octahedra linked with each other by sharing the Te–Te edges. Its crystal structure shows a distorted variant of the 1T CdI$_2$ type, regard as 1Td TMD structure shown in Figure 1c. As summarized in Figure 1d, the 2H and 1Td WSe$_{2(1-x)}$Te$_{2x}$ can be produced by tuning the concentration of Te from 0 to 100% where x = 0–0.4 for 2H structure, x = 0.5 and 0.6 for 2H and 1Td structures, and x = 0.7–1.0 for 1Td structure, confirmed by Energy dispersive X-ray spectroscopy (EDX) (Figure S2), X-ray photoelectron spectroscopy (XPS) (Figure S3, S4, S5 and S6) and the powder X-ray diffraction (XRD) (Figure 1d and S7). It is worth noting that an intermediate state appears with two phases (1Td and 2H) when the concentration of Te increases.

The atomic structure of the layered WSe$_{2(1-x)}$Te$_{2x}$ alloys have been further studied by Z-contrast scanning transmission electron microscopy (STEM). Since the image intensity in Z-contrast STEM imaging is directly related to the atomic number of the imaged species in thin flakes, we only examine the alloyed monolayers exfoliated from the bulk. Figure 2 shows four
typical monolayers with different Te concentration and phases, including 2H WSe$_2$ ($x = 0$, Figure 2a), 2H WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0.5$, Figure 2b), 1Td WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0.5$, Figure 2c) and 1Td WTe$_2$ ($x = 1$, Figure 2d). In pristine WSe$_2$ shown in Figure 2a, the monolayer maintains a hexagonal lattice shape, with alternating bright and less bright spots as W and Se$_2$ atomic columns, respectively, similar to the other reports.[22] The Fast Fourier Transform (FFT) pattern further confirms the hexagonal nature of the lattice. Figure 2b shows a monolayer region exfoliated from 2H WSe$_{1.0}$Te$_{1.0}$ bulk crystal, which displays a hexagonal lattice shape (confirmed by FFT pattern) but exhibits distinguishable atomic column intensity from the pristine WSe$_2$. Te$_2$ columns (the brightest spots in Figure 2b) maintain higher intensity than the W columns due to their heavier atomic weight, while Te+Se and Se$_2$ columns have lower intensity than W, which confirms the successful in-lattice substitution of Te atoms in the Se sites. It is notable that such intensity distribution is similar to the ternary MoS$_{2x}$Se$_{2(1-x)}$ alloys.[5]

Figure 2c shows a monolayer region exfoliated from the 1Td phase bulk crystal with similar chemical composition in Figure 2b. The atomic resolution image confirms the transition from the 2H phase to 1Td, as verified by the zigzag-like chains. FFT pattern further shows the periodicity of the lattice change from hexagonal to orthorhombic. Te atoms, which can be distinguished by its higher intensity than Se atoms, are found to be substituted into either two asymmetric sites in the orthorhombic unit cell of the 1Td phase, as indicated by the structural model. As shown in Figure 2d, further increasing the Te concentration to 100% results in WTe$_2$ in a perfect 1Td phase where the zigzag W–Te and Te chains have uniform intensity distribution along the chain direction without much intensity variance, in sharp contrast to Figure 2c. Moreover, TEM characterizations of thick flakes of WSe$_{2(1-x)}$Te$_{2x}$ with different Te concentrations are also provided in Figure S8. These results confirm the high quality of our as-synthesized bulk crystals. It is notable that although the high-resolution STEM results confirm the atomic structures of the co-existed 2H and 1Td phase in different
WSe_{1.0}Te_{1.0} bulk crystal, we didn’t observe any intrinsic defect (such as dislocations or grain boundaries) except alloyed Te atoms and electron-induced vacancies in both the 2H and 1Td phases, neither phase segregation in the same flake. These results suggest that the phase transition may occur at the very beginning of the growth and continue to form perfect 2H or 1Td lattice structures depending on the initial nucleation. However, it is interesting that phase mixing (2H and 1Td) occurs at some critical range of Te alloy concentration, which requires more effort to investigate the phase transition mechanism inside these WSe_{2(1-x)}Te_{2x} alloys. This will be the topic of our future study of this material system.

Raman spectra of monolayer and bulk of WSe_{2(1-x)}Te_{2x} (x = 0–100%) single crystals have been collected to confirm the phase transformations in the sample with different Te compositions. The WSe_{2(1-x)}Te_{2x} monolayers are prepared by micromechanical exfoliation of WSe_{2(1-x)}Te_{2x} single crystals and transfer their atomic layered samples on SiO_{2}/Si substrate (280 nm oxide layer) using the Scotch tape. The thicknesses of all the samples are identified by atomic force microscopy (AFM), as shown in Figure S10. Raman vibration modes dependent on the concentration of Te are mapped in Figure 3a and 3b, excited by 532 nm laser. For comparison, the typical Raman spectra of WSe_{2(1-x)}Te_{2x} for x = 0, 0.1, 0.2, 0.3, 0.4 and 0.5 are plotted in Figure 3c and 3d for monolayer and bulk samples, respectively. For WSe_{2}, the two characteristic peaks E_{12g} and A_{1g} for monolayer and bulk WSe_{2} are 248.6 and 260.9 cm\(^{-1}\), 245.9 and 255.8 cm\(^{-1}\), respectively, in agreement with previous report.\[^{12, 14, 23-25}\] Increasing the concentration of Te softens these two peaks and make a red-shift, as shown in Figure 3c, which can be contributed to the high frequency vibration due to the heavy Te dopant. This phenomenon is also observed in other TMD alloy such as Se alloyed MoS_{2}. The intensity of the peaks becomes very weak. Meantime, for monolayer sample, the peak locates around 120 cm\(^{-1}\) appears. It is also noticed that in both monolayer and bulk sample, after alloying Te, E_{12g} and A_{1g} vibration modes split into three modes as displayed in Figure 3c and 3d.
As we mentioned above (Figure 1), co-existence of 2H and 1Td phases occurs if the Te mole fraction in $\text{WSe}_{2(1-x)}\text{Te}_{2x}$ alloy is between 0.5–0.6, while only 1Td phase can be found in the samples when $x > 0.6$, a strong evidence that 2H phase is completely translated into 1Td phase in order to realize the translation from semiconductor to metal. In other words, the highest Se alloyed level in Te sites for 1Td $\text{WSe}_{2(1-x)}\text{Te}_{2x}$ alloy is 0.4 in mole fraction. Such upper limit of Se dopant will be crucial for the studies of WTe$_2$ based Wyle semimetals via chalcogen alloying$^{[26-28]}$. Also, it is interesting to examine the evolution of Raman signal of 1Td $\text{WSe}_{2(1-x)}\text{Te}_{2x}$ ($x \geq 0.5$). Figure 4 shows the intensity of Raman vibration modes dependency on the mole fraction of Te and typical Raman spectra for monolayer and bulk 1Td $\text{WSe}_{2(1-x)}\text{Te}_{2x}$ alloy, respectively. As shown in Figure 4a and 4b, two main vibration modes $A^5_1$ and $A^2_1$ (denoted as $A^5_1$ and $A^2_1$, respectively) are found for monolayer and bulk WTe$_2$ are 162.2 and 213.3 cm$^{-1}$, 161.17 and 208.60 cm$^{-1}$, respectively, along with some weak peaks below 150 cm$^{-1}$, which are in agreement with the reported values$^{[18-19]}$. In addition, in order to clearly shown the signatures of the Raman signal, typical Raman spectra are plotted in Figure 4c and 4d ($x = 0.5, 0.6, 0.7, 0.8, 0.9$ and 1.0). Compared with the Raman peaks of bulk WTe$_2$, the peaks from monolayers show considerable blue shifts around 10 cm$^{-1}$. More interestingly, Raman spectra of 1Td $\text{WSe}_{2(1-x)}\text{Te}_{2x}$ alloys with $x = 0.5$ and 0.6 display similar profiles. Such phenomenon is also observed in 2H $\text{WSe}_{2(1-x)}\text{Te}_{2x}$ ($x = 0.5$ and 0.6) alloys. Therefore, it is reasonable to speculate that $\text{WSe}_{2(1-x)}\text{Te}_{2x}$ alloys with $x = 0.5$ and 0.6 (mixture of 2H and 1Td) are intermediate states when the semiconducting 2H alloys transits to the metallic 1Td alloys. This is also supported by our STEM images in Figure 2b and 2c.

Engineering the band gap of 2D materials make them the reality for the wide spectrum of applications. Recently, the carbon-doped boron nitride (BCN) films have been intensively studied so that ternary 2D materials become a promising way. However, the phase separation in BCN film at high temperature make it a challenge to produce homogeneous BCN atomic layers with precious control in the composition, mainly due to the lattice mismatch of h-BN.
and graphene which is not low enough (~ 2.7%). TMDs, consisting of a few families with similar crystal structure make it possible to produce the homogeneous 2D ternary monolayers. TMD alloys, such as Se alloyed MoS$_2$, W alloyed MoS$_2$, etc, have been reported in the past few years.\textsuperscript{[3-9, 29]} But no TMD ternary can provide a transition from semiconductor to metal like what have been reported in BCN films and bulk materials. The WSe$_{2(1-x)}$Te$_{2x}$, consisting of semiconducting WSe$_2$ ($x = 0$) and metallic WTe$_2$ ($x = 1$), make it possible to achieve a much large tunable range of band gap. Photoluminescence (PL) is a good tool to evaluate the optical gap of semiconducting materials, especially band gaps evolution in 2H WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0$–0.6). The photoluminescence (PL) spectra of monolayer samples excited with a 532 nm laser are collected and shown in Figure 5a. All monolayer 2H WSe$_{2(1-x)}$Te$_{2x}$ show the emission bands, and the spectral peak continuously shifts from 744 nm (pure WSe$_2$) to 857 nm (near infrared). For 1Td sample, as expected, no PL signal is detected when $x \geq 0.6$. Figure 5b plots the optical gap vs mole fraction of Te for monolayer WSe$_{2(1-x)}$Te$_{2x}$. The band gaps are continuously shifted from 1.67 eV (pure WSe$_2$) to 1.44 eV. Interestingly, it can be found that the optical gaps are similar when $x = 0.5$ and 0.6, indicating the highest concentration of Te dopant in 2H WSe$_{2(1-x)}$Te$_{2x}$ alloy is 0.6, which is well agreement with the Raman data. At the same time, the optical gap directly changes from 1.44 eV (2H semiconductor) to 0 eV (1Td metal) in this regime. The optical gaps are 0 eV when $x > 0.6$, confirming that the WSe$_{2(1-x)}$Te$_{2x}$ alloys undergo a phase transition from semiconductor (2H phase) to metal (1Td phase). The band gaps of 2H WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0$–0.6) monolayers, bilayers and bulk are calculated in Figure S11, basically consistent with our experimental result. In addition, the calculated results also show 2H Te alloyed WSe$_2$ monolayer is a direct-gap semiconductor and 1Td WTe$_2$ monolayer is metallic (Figure S12 and S13). Interestingly, the strong optical second harmonic generation (SHG) are found in 2H WSe$_2$, 2H WSe$_{1.8}$Te$_{0.2}$, 2H WSe$_{1.4}$Te$_{0.6}$ and 2H WSe$_{1.2}$Te$_{0.8}$ monolayers (Figure S14), which show the break of inversion symmetry is happen in monolayer. With the increase of the mole fraction of Te, the
intensities of SHG become weaker, which may be ascribed to the differences of the polarization or the absorbency of the samples with the different concentration of Te. The SHG polarization dependence of 2H WSe$_2$ and 2H WSe$_{1.4}$Te$_{0.6}$ monolayers (Figure S15 and S16) are also investigated, which show the samples display three-fold rotational symmetry, in accordance with the $D_{3h}$ symmetry.$^{[30-32]}$

The FET devices based bilayer 2H WSe$_{2(1-x)}$Te$_{2x}$ (x = 0 and 0.3) and 1Td WSe$_{2(1-x)}$Te$_{2x}$ (x = 0.7 and 1) have been fabricated on SiO$_2$/Si (280 nm oxide layer) substrate in order to further confirm the semiconducting 2H phases and metallic 1Td phases. The Ti/Au electrodes are deposited by e-beam evaporation after photolithography (Figure S17). The optical images of devices are shown in the center of Figure 6. The current–voltage ($I_{ds}$–$V_{ds}$) curve and the transfer characteristics ($I_{ds}$–$V_{bg}$) of the WSe$_{2(1-x)}$Te$_{2x}$ transistors are displayed in Figure 6 a–g.

By increasing the alloyed level of Te from 0 to 0.3, the drain current increases from around 1.7 nA to 10 nA at a drain voltage of 2V and no gating voltage. The transfer characteristics clearly show a p-type semiconducting behavior for both samples, consistent with the theoretical results and previous literatures.$^{[12-13, 33]}$ The mobility of the carriers can be calculated by

$$\mu = \frac{L}{W \times (\varepsilon_0 \varepsilon_r / d)} \frac{dI_{ds}}{dV_g} \times \frac{1}{V_s},$$

and the thickness of SiO$_2$ layer (285 nm in our devices), respectively.$^{[34]}$ $V_{ds}$, $I_{ds}$ and $V_b$ denote the source–drain bias, current, and bottom gate voltage in the linear region in the $I_{ds}$–$V_g$ curve. $\varepsilon_0$ and $\varepsilon_r$ are the vacuum dielectric constant and the dielectric constant of SiO$_2$ ($\varepsilon_r = 3.9$), respectively. The calculated mobility and on/off ratio of bilayer 2H WSe$_{2(1-x)}$Te$_{2x}$ for x = 0 and 0.3 are 10 cm$^2$V$^{-1}$s$^{-1}$ and $10^6$, 46 cm$^2$V$^{-1}$s$^{-1}$ and $10^6$, respectively. For x = 0.7 and 1.0, as expected, no drain current dependency is found on the gating voltage, suggesting that 1Td WTe$_2$ and WSe$_{0.6}$Te$_{1.4}$ are metallic. It is also noticed that, for x = 0.7, the drain current is around 20 nA at a drain voltage of 2V. For x = 1.0, that is pure WTe$_2$, the drain current increases more than 3 orders of magnitude, reach to around 40 µA. It indicates that the
metallic behavior of WTe$_2$ could be considerably impacted by alloying Se. In addition, the plots of the resistance with the dependence of temperature (Figure S18) also confirm that 2H WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0$ and 0.3) are semiconductors and 1Td WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0.7$ and 1) are metals because the resistances decrease with increasing temperature for the former, but increase with increasing temperature for the latter.

In conclusion, the phase transition of TMD monolayer from semiconductor to metal has been demonstrated by alloying Te into tungsten diselenide. Using one-step chemical vapor transport (CVT), the complete composition of WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0$–1) alloys are obtained, which exhibit distinguishable semiconducting 2H and metallic 1Td phase. Three regions (2H phase, the coexistence of 2H and 1Td phase, and 1Td phase) are identified in the complete composition WSe$_{2(1-x)}$Te$_{2x}$ ($x = 0$–1) alloy using Energy dispersive X-ray spectroscopy (EDXS) and Raman spectroscopy. STEM images clearly confirm the semiconducting and metallic WSe$_{2(1-x)}$Te$_{2x}$ alloys showing the hexagonal and orthorhombic lattices, respectively, and the random distribution nature of the Se and Te atoms arrangements in these alloys is also found. The photoluminescence (PL) spectra show that the optical band gaps of the WSe$_{2(1-x)}$Te$_{2x}$ monolayer can be tuned from 1.67 eV to 1.44 eV (2H semiconductor) and drop to 0 eV (1 Td metal). Additionally, WSe$_{2(1-x)}$Te$_{2x}$ atomic layer based FET devices confirm that 2H phase is p-type semiconductor but 1Td phase is metal. It is noted that the p-type bilayer 2H WSe$_2$ and 2H WSe$_{1.4}$Te$_{0.6}$ field-effect transistors exhibit excellent electronic characteristic with effective hole carries mobility up to 10 and 46 cm$^2$V$^{-1}$s$^{-1}$ and on/off ratios up to $10^6$, respectively. These band gap engineering 2D structures could open up an exciting opportunity for not only probing their fundamental physical properties in 2D such as new type of Wyle semimetals and spin Hall effect but diverse applications in functional electronic/optoelectronic devices.

Experimental
Submitted to Advanced Materials

Synthesis and mechanical exfoliation of $WSe_{2(x-1)}Te_{2x}$ ($x = 0–1$) single crystals: Single crystals of $WSe_{2(x-1)}Te_{2x}$ ($x = 0–1$) were prepared by the method of chemical vapor transport (CVT) with iodide as the transporting agency. The stoichiometric amounts of high purity W, Te and Se with the weight of 0.3 g and 40 mg iodide were sealed in an evacuated 20 cm-long quartz tube under vacuum at $10^{-6}$Torr, which was placed in a three-zone furnace. The reaction zone was pretreated at 850 °C for 30 h with the grown zone at 900 °C, preventing the transport of the samples. The reaction zone was then programmed at a higher temperature of 1010 °C with the growth zone at a lower temperature of 900 °C for three days to provide a temperature gradient for the growth of single crystal. Finally, the furnace was naturally cooled down to room temperature and the single crystal of $WSe_{2(x-1)}Te_{2x}$ ($x = 0–1$) can be collected in the growth zone. 2H and 1Td $WSe_{2(x-1)}Te_{2x}$ single crystals show different shapes with the platelet and ribbon, respectively, shown in Figure 1a. Monolayer $WSe_{2(x-1)}Te_{2x}$ ($x = 0–1$) were mechanically exfoliated from bulk $WSe_{2(x-1)}Te_{2x}$ single crystals and transferred to a silicon substrate with a 280 nm thick silica layer using the scotch tape-based mechanical exfoliation method, which was widely employed for preparation of monolayer graphene and transitional metal dichalcogenides (TMD).

TEM sample preparations and image simulations: The synthesis of $WSe_{2(x-1)}Te_{2x}$ ($x = 0.5–0.6$) yielded out samples with two distinct morphologies (2H and 1Td phase). We fabricated the TEM samples of 2H and 1Td phases by exfoliating the corresponding bulk crystals (different shape) separately, and then transferred the exfoliated flakes onto Au grid with carbon film via a conventional wet-transfer method with the assistance of PMMA. The Z-contrast STEM imaging were done with a modified JEOL 2100F with delta probe corrector, which corrects the aberration up to 5th order, resulting in a probe size of 1.4 Å. The imaging was conducted at an acceleration voltage of 60 kV. The convergent angle for illumination is about 35 mrad, with a collection detector angle ranging from 62 to 200 mrad.
The fabrication and measurements of the devices: The devices were fabricated by photolithography and Ti/Au or Ti/Cr (20nm/80nm) as contact electrodes were deposited using electron-beam evaporation. The channel lengths and widths of the fabricated devices are 6 and 7 μm for 2H WSe₂, 8 and 5 μm for 2H WSe₁.₄Te₀.₆, 6 and 4 μm for 1Td WSe₀.₆Te₁.₄, and 6 and 5 μm for 1Td WTe₂. The final devices were annealed at 400°C for 2 h with the protection of nitrogen in order to remove resist residues and enhance the metallic contacts. Electrical characterization was performed by current–voltage measurements on a probe station equipped a semiconductor characterization system AgilentB1500A.

Acknowledgements
This work was supported by the National Research Foundation Singapore under NRF RF Award No.NRF-RF2013-08. This work as also supported by MOE2011-T2-2-147 and MOE2011-T3-1-005 from Ministry of Education, Singapore. JL and KZ acknowledge support from the JST Research Acceleration Program. H.L. acknowledges the Singapore National Research Foundation for the support under NRF Award No. NRF-NRFF2013-03. †These authors contributed equally to this work.

Received: ((will be filled in by the editorial staff))
Revised: ((will be filled in by the editorial staff))
Published online: ((will be filled in by the editorial staff))


[34] X. Liu, J. Hu, C. Yue, N. Della Fera, Y. Ling, Z. Mao, J. Wei, ACS Nano 2014, 8, 10396-10402.
Figure 1. Morphologies of as-grown WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–1) alloys. (a) Photographs of as-grown WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–1) single crystals on the millimeter-grid paper, and 2H and 1Td types TMD alloys show circularly platy and bar shapes, which are in agreement with hexagonal and orthorhombic crystal systems, respectively. (b) The crystal structure of 2H WSe$_2$. (c) The crystal structure of 1T' WTe$_2$. (d) Different phases with dependence of concentration x in WSe$_{2(1-x)}$Te$_{2x}$. 
Figure 2. Atomic resolution STEM characterization of WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–1) alloyed monolayers with different Te concentration. (a–d) Z-contrast STEM images showing the atomic structure of pristine WSe$_2$ monolayer in 2H phase (a), alloyed WSe$_{1.0}$Te$_{1.0}$ monolayer in 2H phase, alloyed WSe$_{1.0}$Te$_{1.0}$ monolayer in 1T$_d$ phase and monolayer WTe$_2$ in 1T$_d$ phase. Corresponding FFT patterns are shown in the inset. Te$_2$, Te+Se and Se$_2$ atomic columns in the 2H phase, as well as the Te and Se atoms in the 1T$_d$ phase, can be distinguished by image intensity. The atomic models are just for schematic purpose. Scale bar: 0.5 nm
Figure 3. The Raman characterization of bulk and monolayer 2H WSe$_{2-x}$Te$_x$ (x = 0–0.6) alloys. Raman intensity of monolayer (a) and bulk(b) 2H WSe$_{2-x}$Te$_x$ (x = 0–0.6) alloys with the different Te compositions. Raman spectra of monolayer (c) and bulk (d) 2H WSe$_{2-x}$Te$_x$ (x = 0–0.6) alloys. The intensities of the W–Se related modes (E$_{2g}$(W–Se) and A$_{1g}$(W–Se)) gradually decrease with Te mole fraction increases for monolayer and bulk samples, as shown in Figure a and b. Moreover, a red-shift and splits of E$_{2g}$(W–Se) and A$_{1g}$(W–Se)vibration modes with Te mole fraction decreases happen.
Figure 4. The Raman characterization of bulk and monolayer 1Td WSe$_{2(1-x)}$Te$_{2x}$ \( (x = 0.6–1) \) alloys. Raman intensity of monolayer (a) and bulk (b) 1Td WSe$_{2(1-x)}$Te$_{2x}$ \( (x = 0.6–1) \) alloys with the different Te compositions. The intensities of the W–Te related vibration modes \( (A^5_{1(W–Te)} \text{ and } A^2_{1(W–Te)}) \) uniformly decrease with the concentration of Te increases from \( x = 0.6 \) to 1 for monolayer and bulk. Raman spectra of monolayer (c) and bulk (d) 1Td WSe$_{2(1-x)}$Te$_{2x}$ \( (x = 0.6–1) \) alloys are shown, which show that the \( A^5_{1(W–Te)} \) and \( A^2_{1(W–Te)} \) vibration modes make a red-shift and become sharp with the concentration of Te increases from \( x = 0.6 \) to 1.
Figure 5. The photoluminescence (PL) spectra of monolayer WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–1.0) alloys. (a) the PL spectrum of the composition monolayer 2H WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–0.6) alloys. (b) the PL measurements of the composition monolayer 1Td WSe$_{2(1-x)}$Te$_{2x}$ (x = 0.5–1.0) alloys. (c) composition-dependents (x) bandgaps of the monolayer WSe$_{2(1-x)}$Te$_{2x}$ (x = 0–0.6) alloys.
Figure 6. The electrical property of the fabricated 2H WSe$_{2(1-x)}$Te$_{2x}$ (x = 0, 0.3) and 1Td WSe$_{2(1-x)}$Te$_{2x}$ (x = 0.7, 1) bilayer FET. Gating response ($I_{ds}$–$V_{bg}$) with a source–drain voltage ($V_{ds}$) of 0.1 V and the current–voltage ($I_{ds}$–$V_{ds}$) curves with different bottom gate voltage of 2H WSe$_2$ (a and b), 2H WSe$_{1.4}$Te$_{0.6}$ (c and d), 1Td WSe$_{0.6}$Te$_{1.4}$ (e and f), and 1Td WTe$_2$ (g and h) bilayer FETs, whose optical images of the fabricated device are shown in the circular ring, respectively.
The metal-semiconductor phase-transition in the TMD ternary monolayer was achieved by doping Te into WSe$_2$ (WSe$_{2(1-x)}$Te$_{2x}$, where $x = 0 \sim 100\%$). Controlling the Te concentration leads to two distinct phases: semiconducting 2H ($x \leq 60\%$) and metallic 1Td phase ($x \geq 50\%$). The optical band gaps of the WSe$_{2(1-x)}$Te$_{2x}$ monolayer can be tuned from 1.67 eV to 1.44 eV (2H semiconductor) and drop to 0 eV (1Td metal), which open up an exciting opportunity in functional electronic/optoelectronic devices.
Production Data

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